

Space charge simulation of RCS and MR

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Thanks K.J. Fan, H. Hotchi, S. Igarashi, H. Kobayashi, T. Koseki,
A. Molodozhentsev, Y. Sato, Y. Shobuda

Introduction

- Target of J-PARC, RCS 1MW, MR 750 kW at 201x.
- Many simulations have been performed to draw a strategy for the design intensity by S. Machida, A. Molodozhentsev, H. Hotchi, K. Fan...
- The intensity is very hard to achieve especially for MR.
- I have developed a code (SCTR) to understand what, how is difficult, and how to do.
- Close linking of RCS and MR is important to achieve the high intensity.
- Unified simulation of RCS and MR may give something new for the strategy toward the target.

Simulation code (SCTR)

- Particle in Cell code based on FACR 2 D potential solver.

$$\Delta_{\perp}\phi = \rho \qquad \Phi = \frac{Nr_p}{\beta^2\gamma^3} \lambda(z)\phi(x,y:s)$$

$\lambda(z)$: Beam line density

- 6D symplectic map for space charge and accelerator elements.

$$\frac{\Delta p_x}{\Delta s} = -\frac{\partial\Phi}{\partial x}, \quad \frac{\Delta p_y}{\Delta s} = -\frac{\partial\Phi}{\partial y}, \quad \frac{\Delta p_z}{\Delta s} = -\frac{\partial\Phi}{\partial z}$$

- Long term simulation, 20ms and 1sec for RCS and MR, respectively.

Two methods, two stage of computing for long term simulations

1. Potential is solved each Δs step, using common memory computers, PC and Hitachi Super Computer. RCS and early stage of MR.
2. Potential is solved every 50-turns and is frozen during the 50-turns period, using a parallel computer, Blue Gene L. Acceleration process in MR.

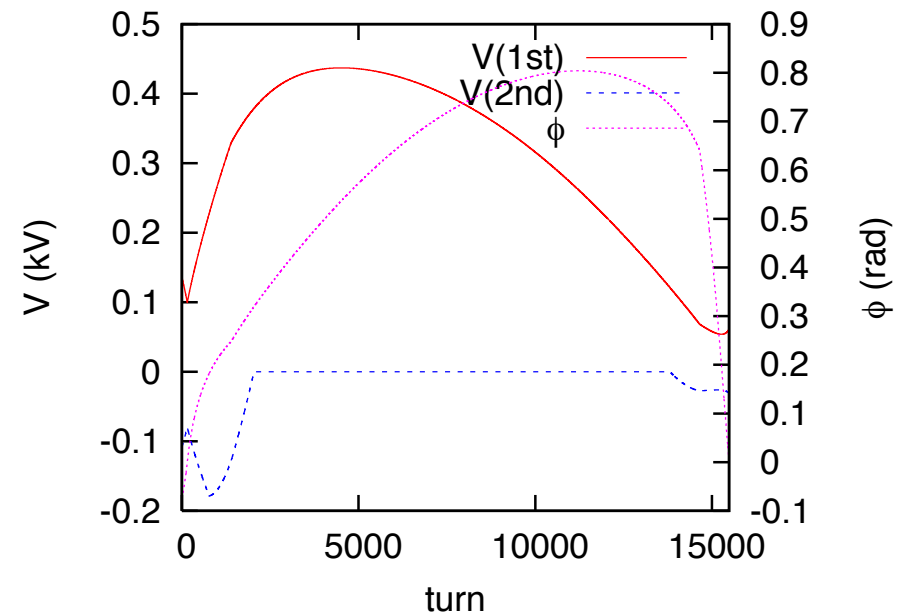
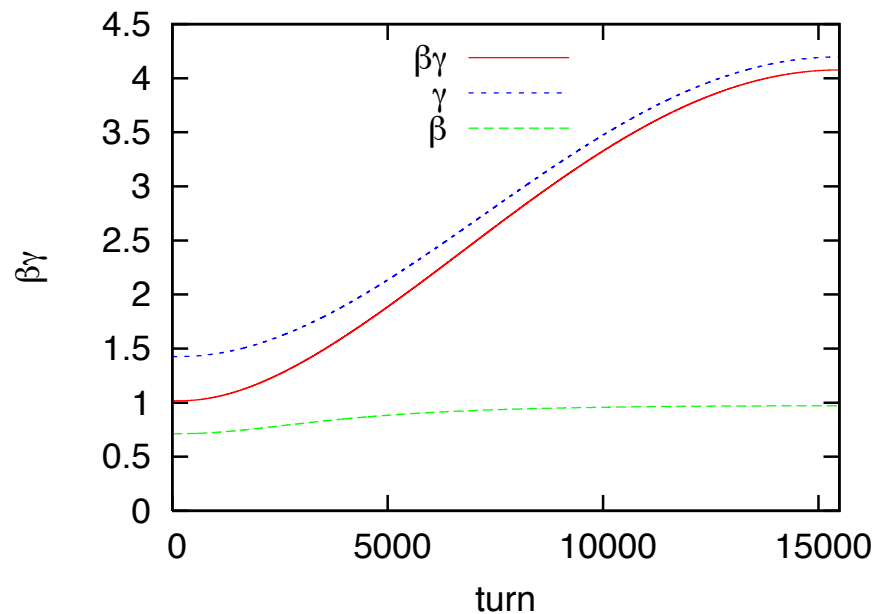
Parameter list of J-PARC

Table 1 Parameter list of J-PARC RCS and MR. ↵

↵	RCS ↵	MR ↵
Kinetic Energy (GeV) ↵	0.4-3 ↵	3-30 ↵
Circumference (m) ↵	349 ↵	1567 ↵
Bunch population, N_p ↵	4.17×10^{13} ↵	4.17×10^{13} ↵
Number of bunch (Harm.) ↵	2 (2) ↵	8 (9) ↵
Repetition (Hz) ↵	25 ↵	0.45 ↵
Beam power (MW) ↵	1 ↵	0.72 ↵
Emittance (collimation)(m) ↵	$\sim 324 \times 10^{-6}$ ↵	$\sim 65 \times 10^{-6}$ ↵

RCS acceleration

- 400 MeV injection, start from Oct. 2012.



By H. Hotchi

Paint injection in RCS

- Emittance of LINAC beam is $0.28(4\pi) \mu\text{m}$.
- Study painting with $J_x + J_y = 100, 150, 200\pi \mu\text{m}$

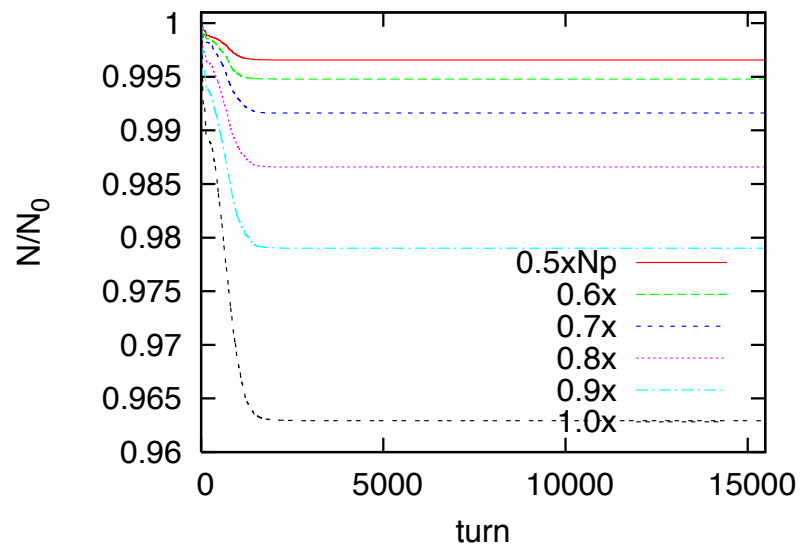
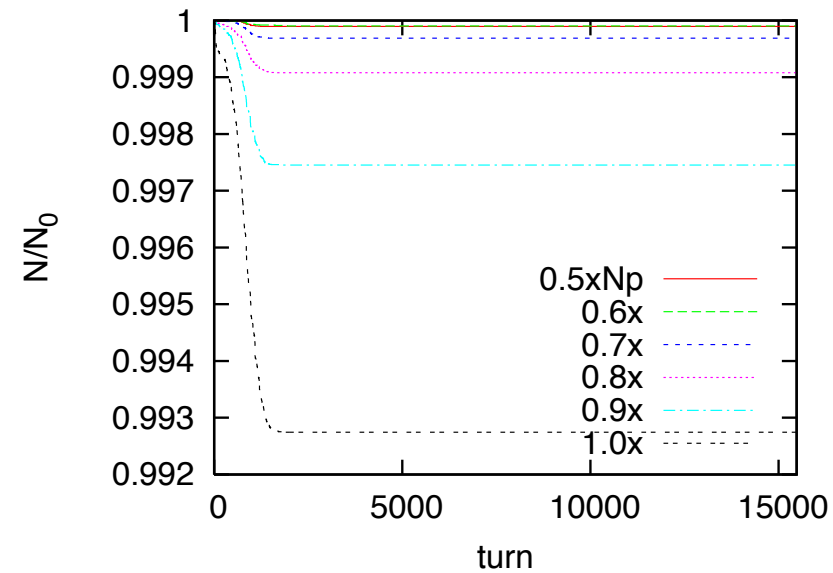
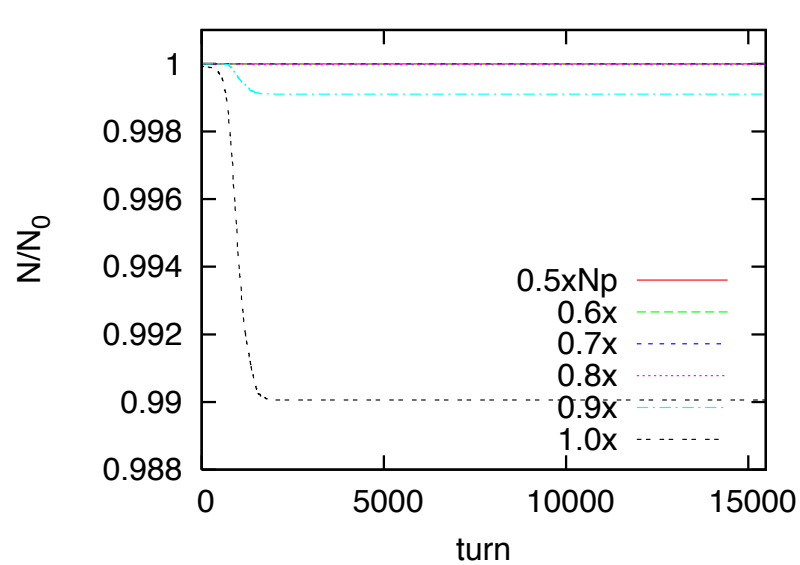
$$J_x = \gamma_x x^2 + 2\alpha_x x p_x + \beta p_x^2$$

Note the factor 2

- Initial spread of $J_x + J_y$ is less than 10%.
- Betatron phase is expected to be smeared.
- We use KV distribution at RCS injection in this presentation.
- Elliptic distribution in the longitudinal with emittance of $0.28\pi \text{ m}$.
- This KV is not perfect one, because of the longitudinal profile, dispersion, chromaticity...

RCS beam loss

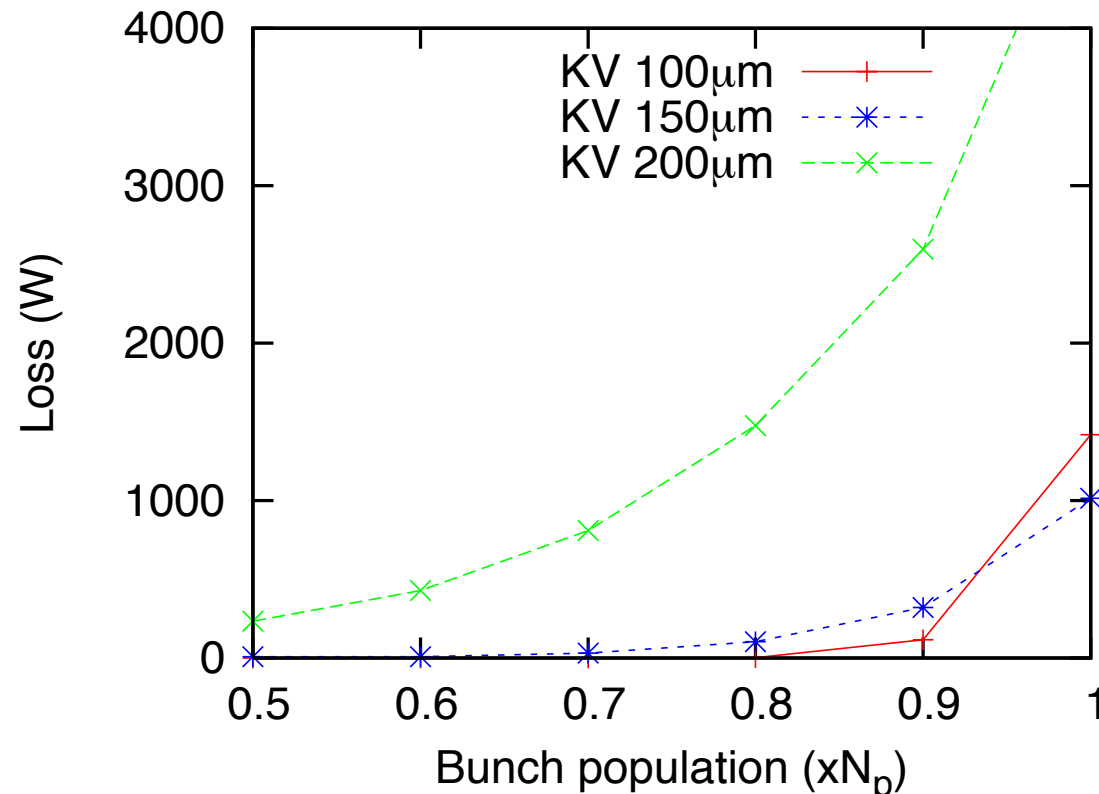
- Initial KV 100, 150, 200 μm



$$v_x, v_y = 6.42, 6.39$$

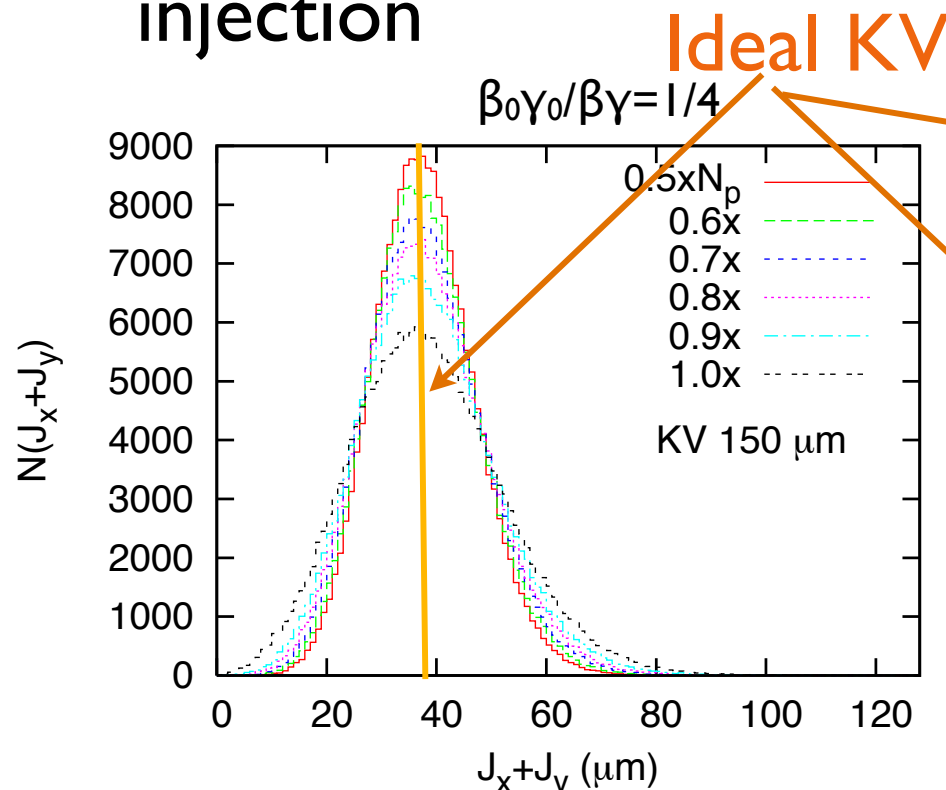
RCS beam power loss

- Whole acceleration process $f_{rep}=25\text{Hz}$



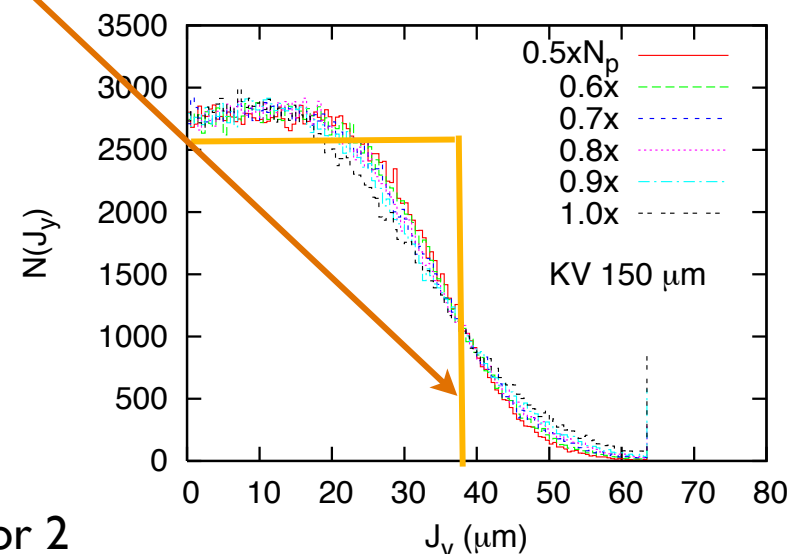
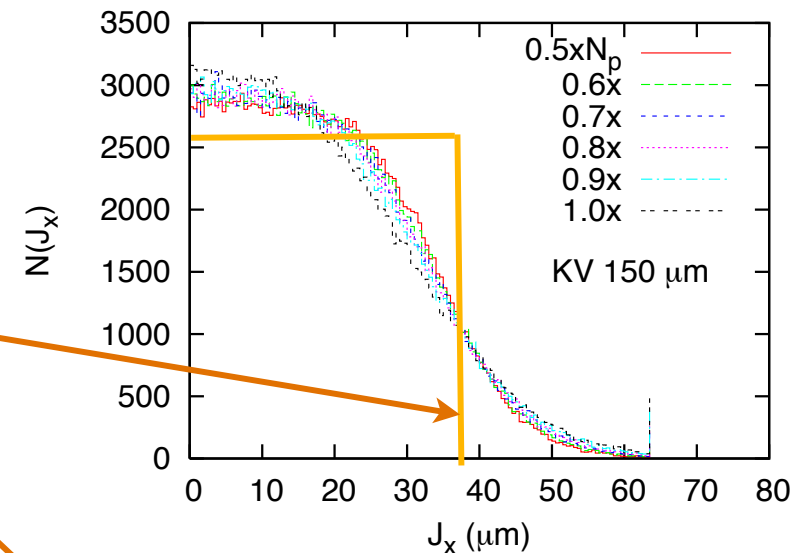
Beam distribution at the RCS extraction I

- KV 150 π μm at 400 MeV injection



$$J_x = \gamma_x x^2 + 2\alpha_x x p_x + \beta p_x^2$$

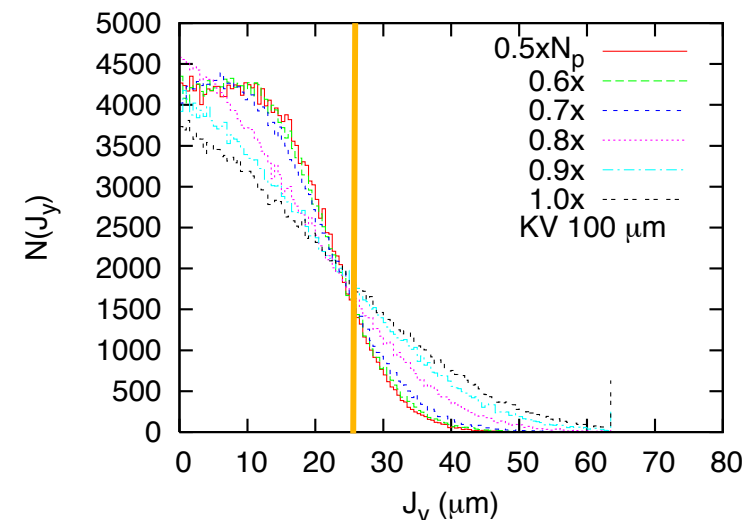
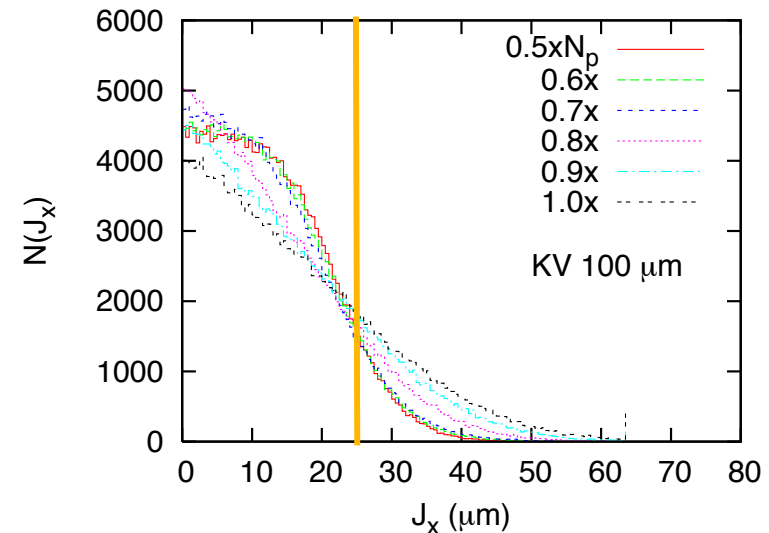
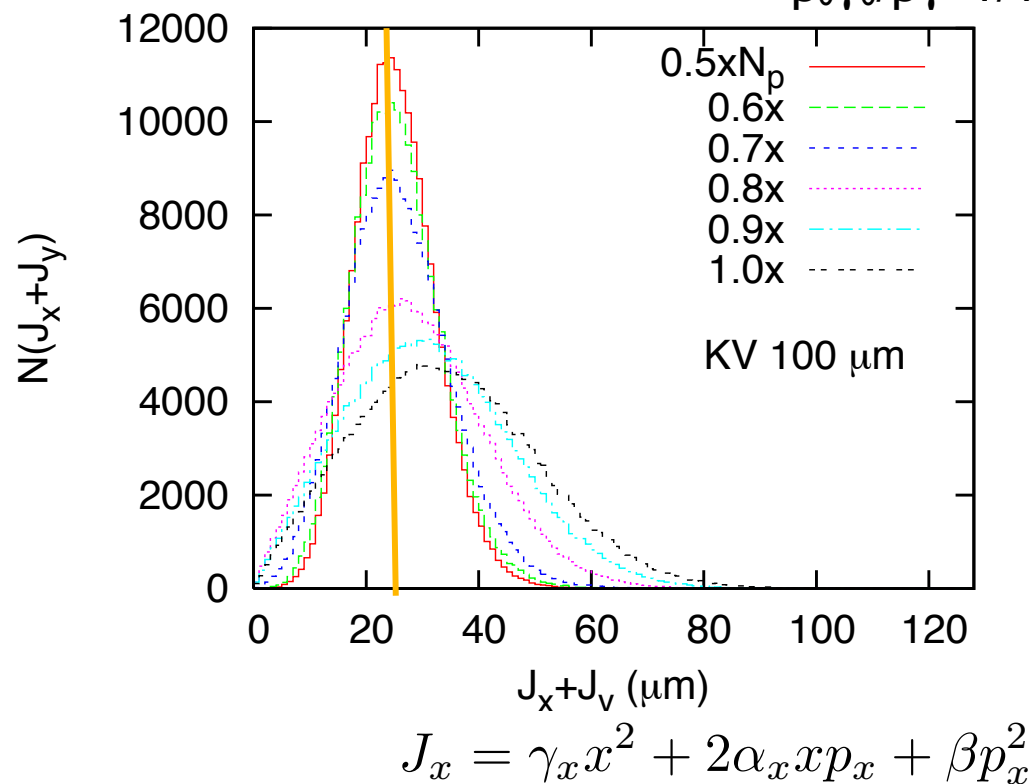
Note the factor 2



Beam distribution at the RCS extraction II

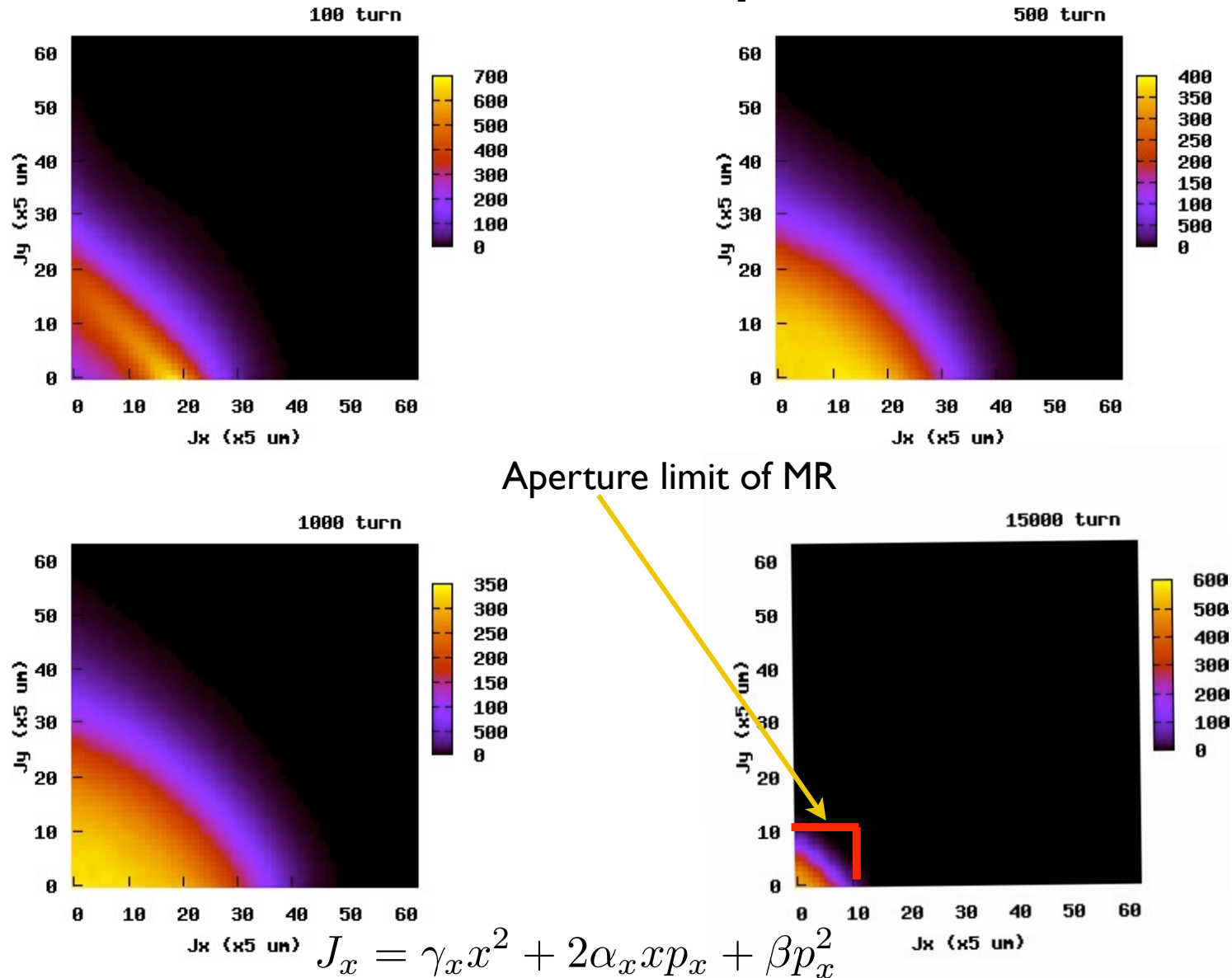
- KV 100 μm at 400 MeV injection

$$\beta_0\gamma_0/\beta\gamma=1/4$$



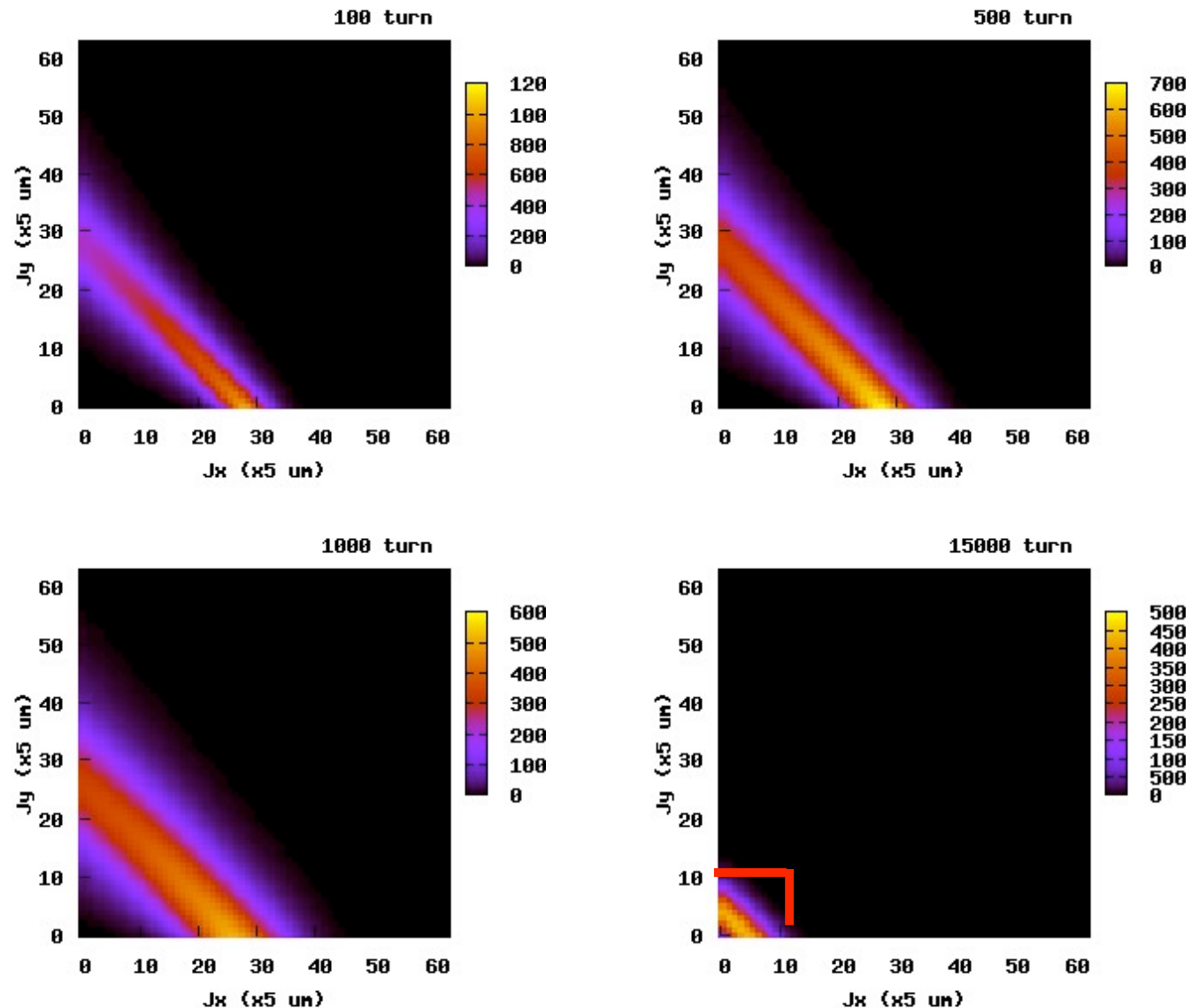
Particle distribution in Jx-Jy

- RCS IMW KV100 π μm



Particle distribution in Jx-Jy

- RCS IMW KV150 π μm

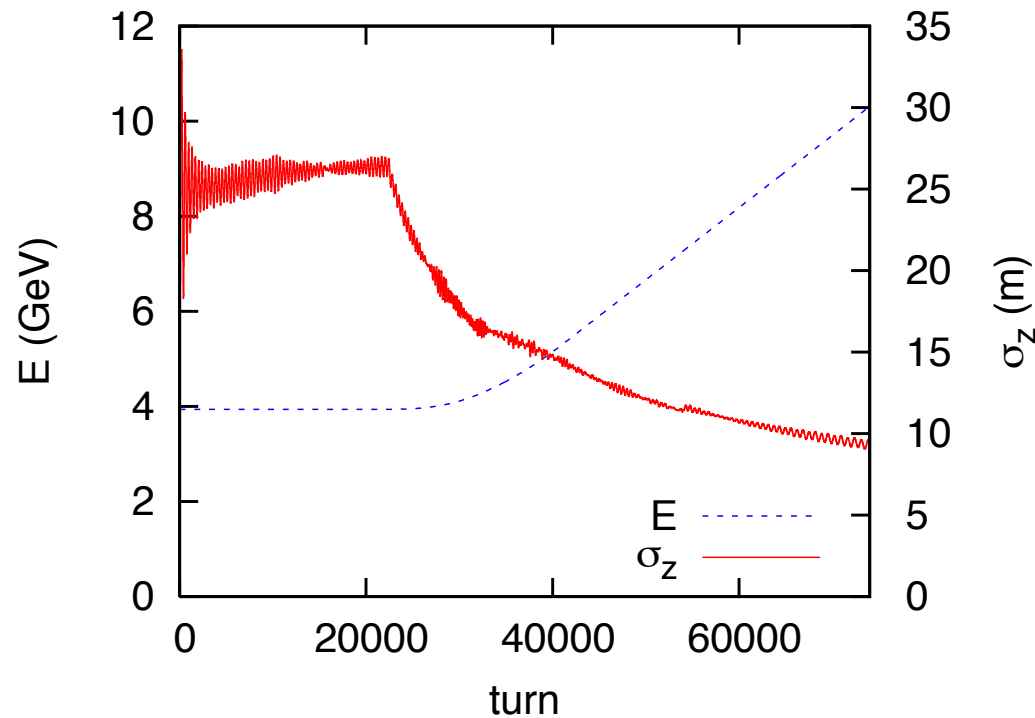


Tentative summary of RCS simulation

- KV distribution is broken an early stage of the simulation.
- Mismatch due to the space charge force may affect.
- The realistic painting process will be done in the simulation.

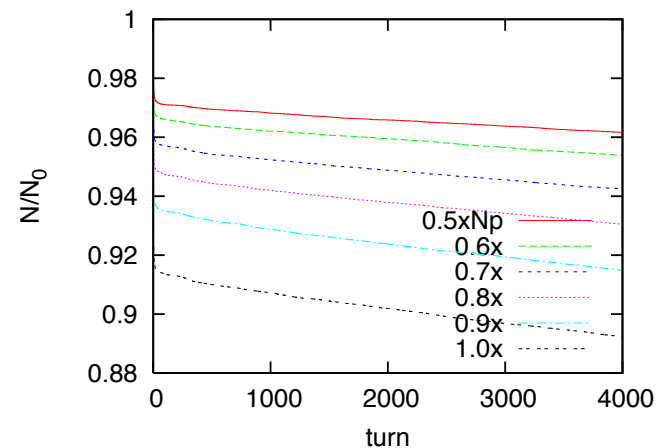
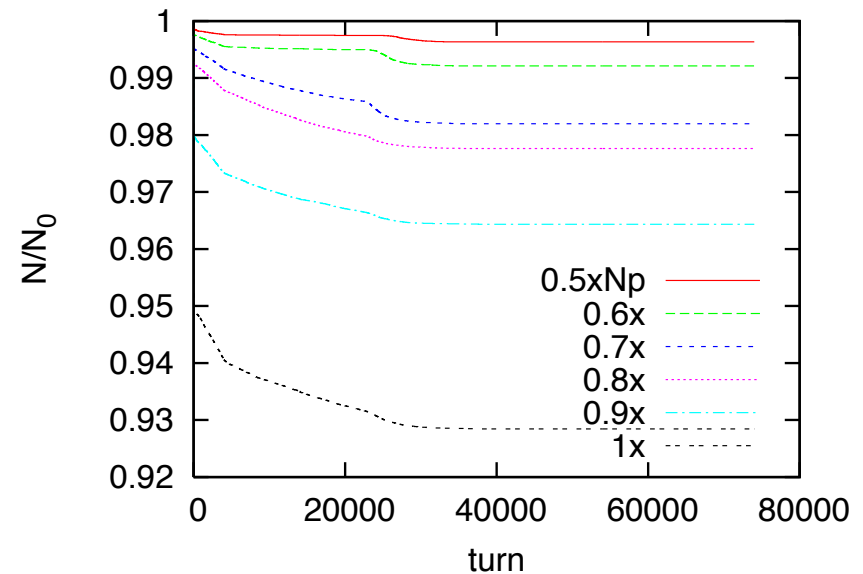
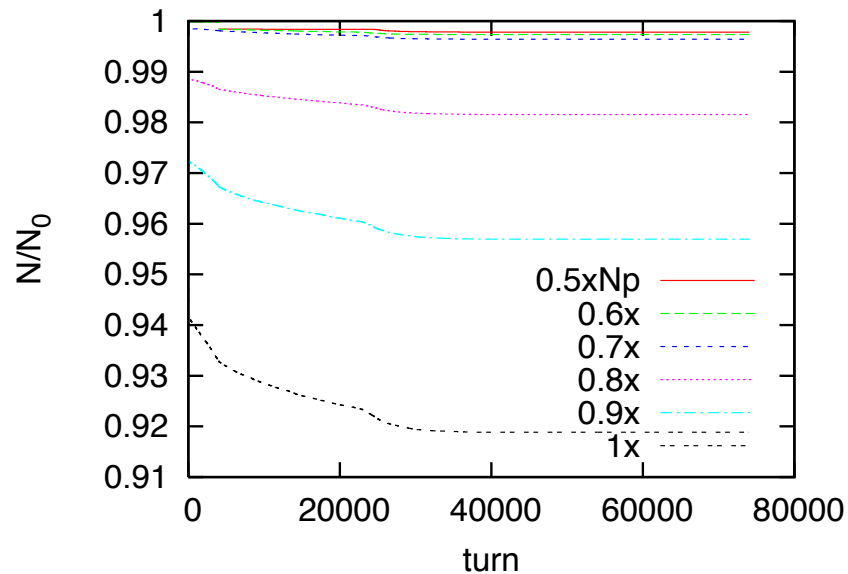
MR acceleration

- Injection, $V_1=140\text{kV}$, $V_2=91\text{kV}$ ($t=0$)
- Acceleration, $V_1=390\text{kV}$, $\Phi=0.4$ rad



MR beam loss

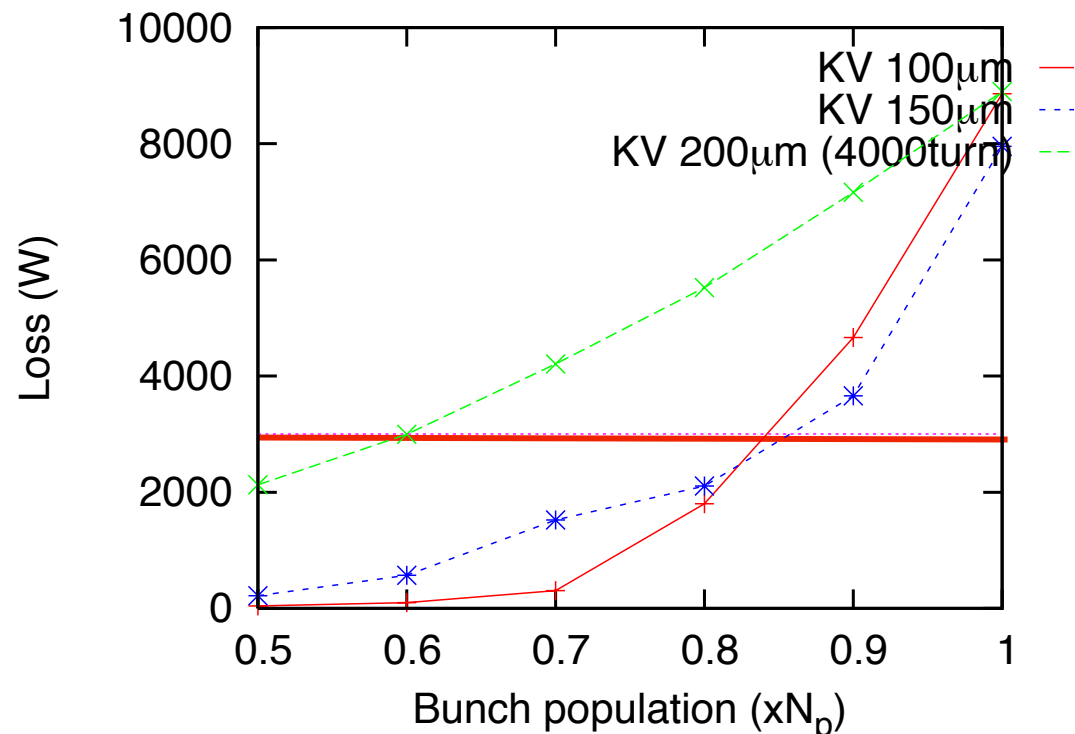
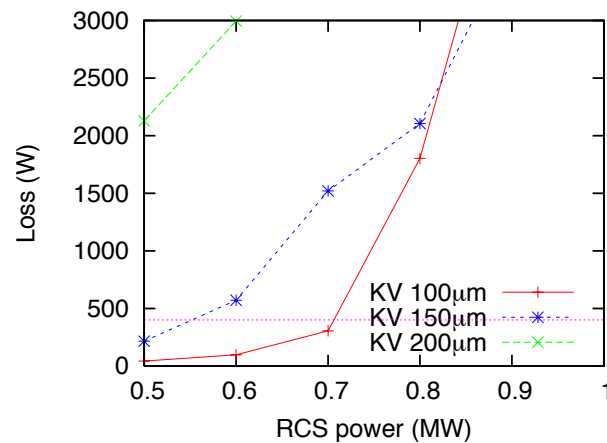
- Inject RCS beam, KV 100, 150, 200 π μm @RCS injection



$$v_x, v_y = 22.15, 20.75$$

MR beam power loss

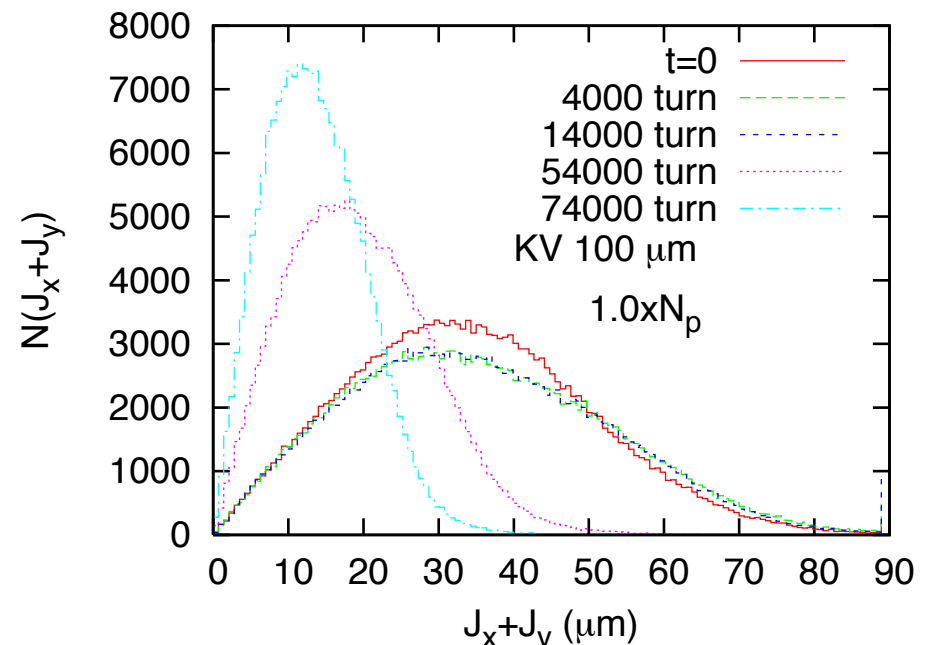
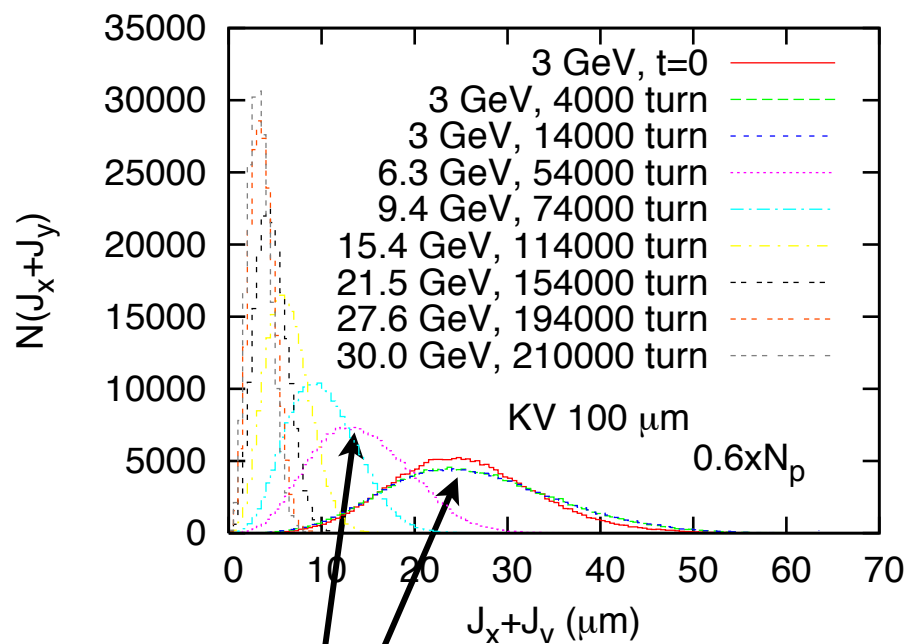
- $f_{\text{rep}}=0.45\text{Hz}$



Limit~3kW, 3-50BT and MR

MR particle distribution

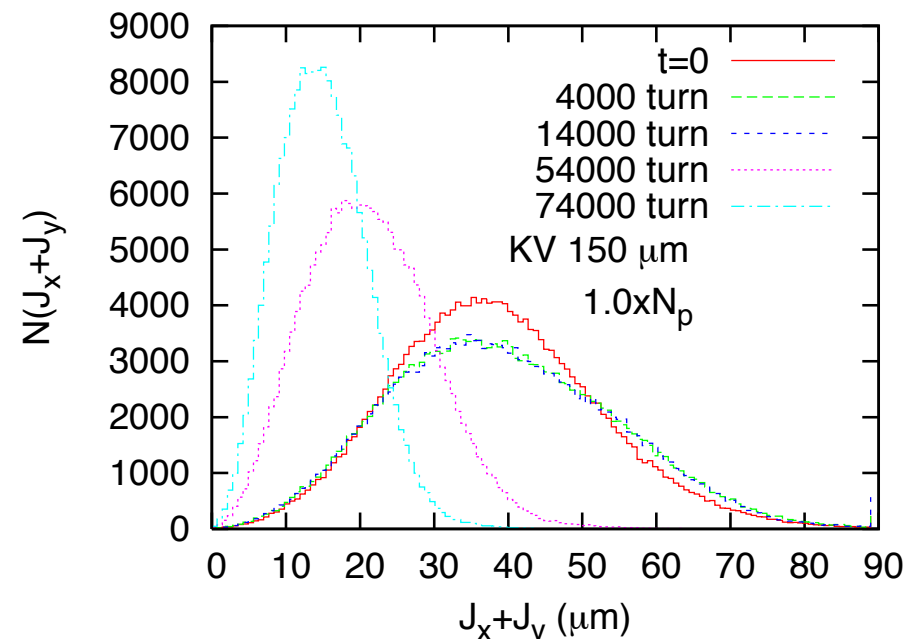
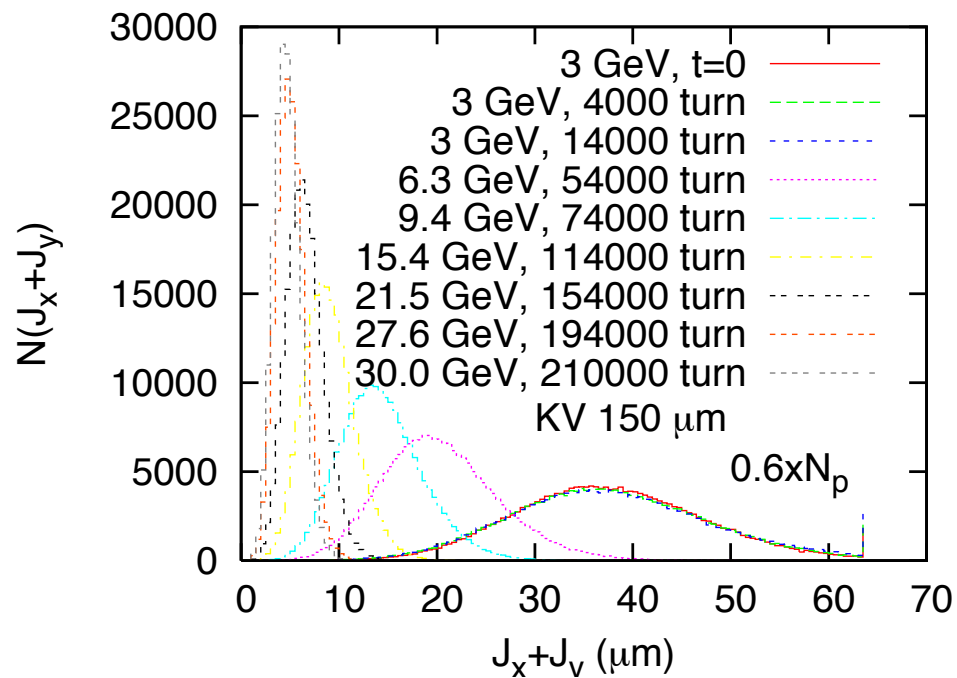
- RCS KV 100 μm
- KV distribution is broken for $N_p = 4.17 \times 10^3$.



Gaussian shape - remains of KV

MR particle distribution

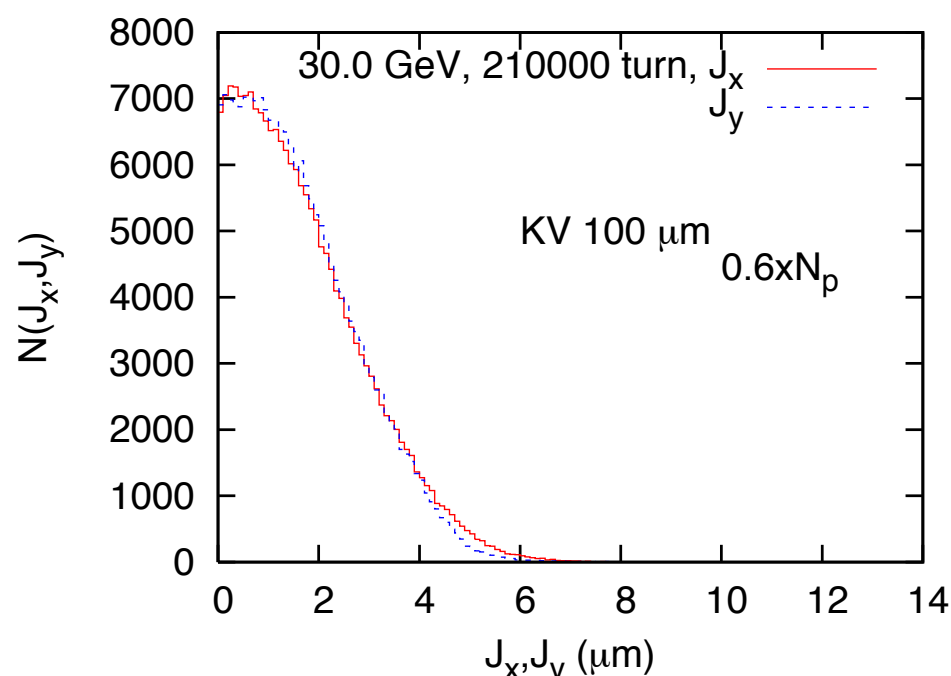
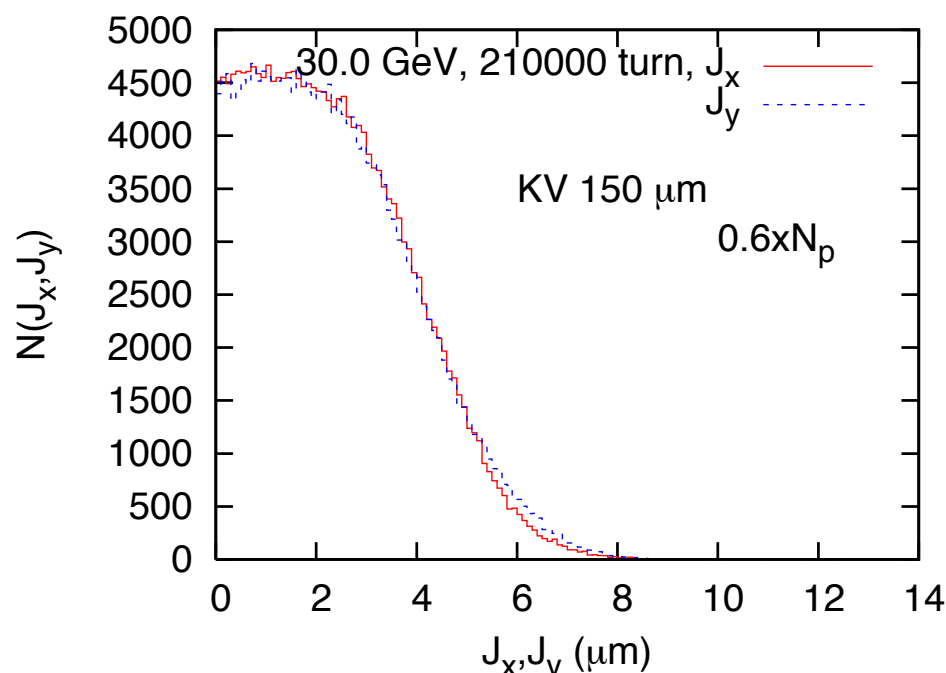
- RCS KV $150\pi \mu\text{m}$
- Remains of KV are seen.



J_x, J_y distribution at 30 GeV

KV 150 π μm @RCS inj

100 π μm @RCS inj



3.8 % and 0.43 % for 6 π μm . $\sim 8\pi$ μm is necessary.
Beam loss limit at the extraction is ~ 100 W ($\sim 0.01\%$) for
6-10 π μm

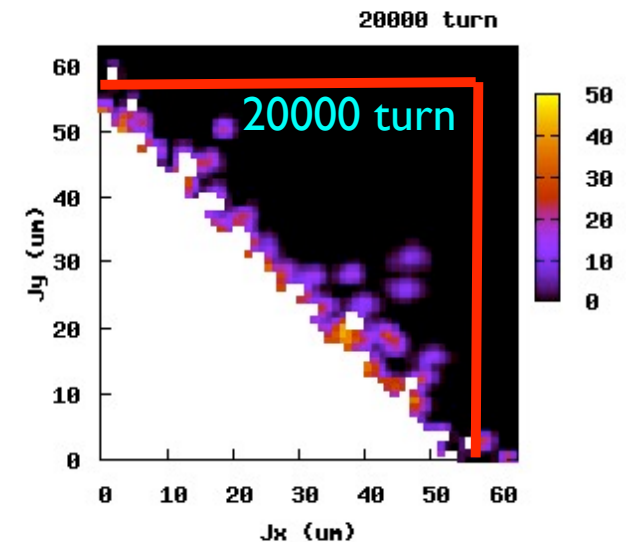
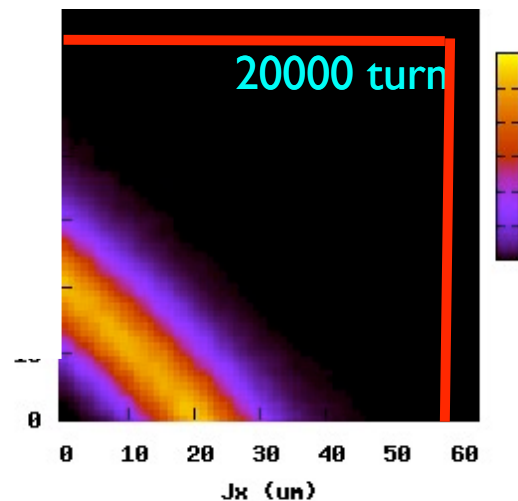
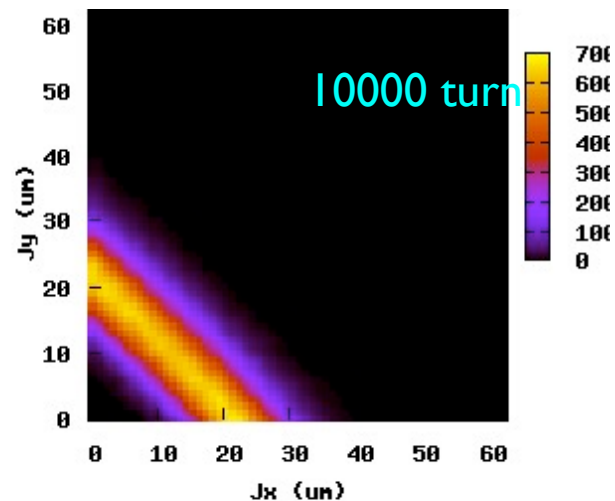
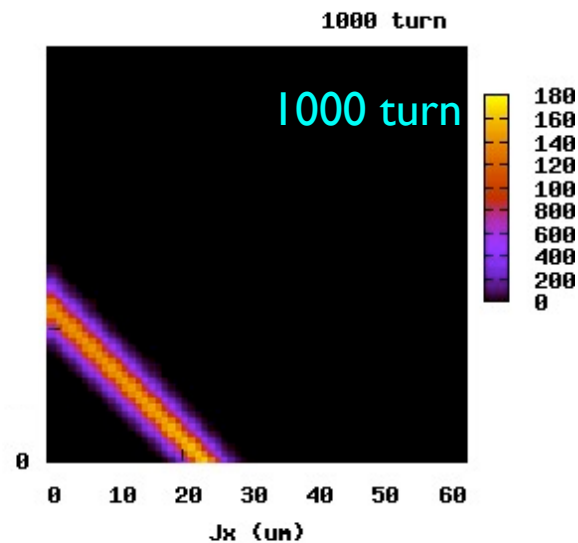
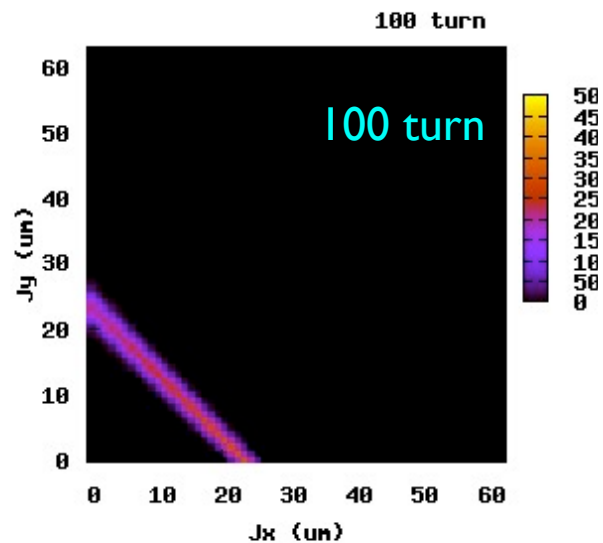
Initialize with KV distribution for $N_p=4.17 \times 10^{13}$ at the MR injection

- $J_x+J_y=25$ or $37.5\pi \mu\text{m}$, 1/4 of RCS, because of $\beta\gamma$ ratio, 1/4.
- Next two slides show spreading of J_x+J_y .
- Numerical noise affects the spread of J_x+J_y . Frozen model gives better result.

Spreading of $J_x + J_y$

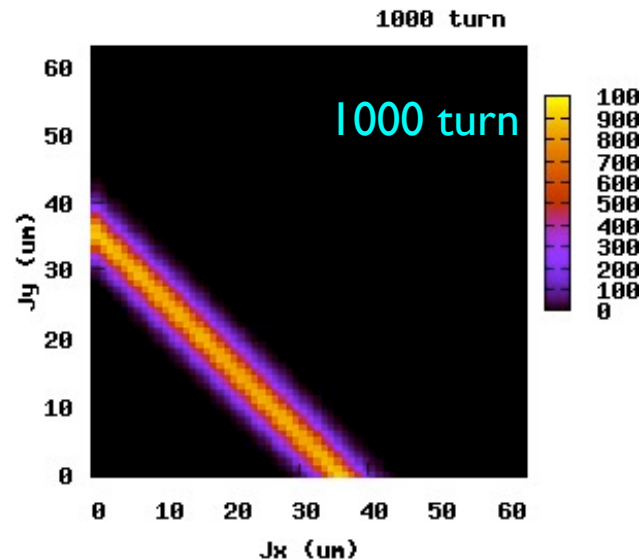
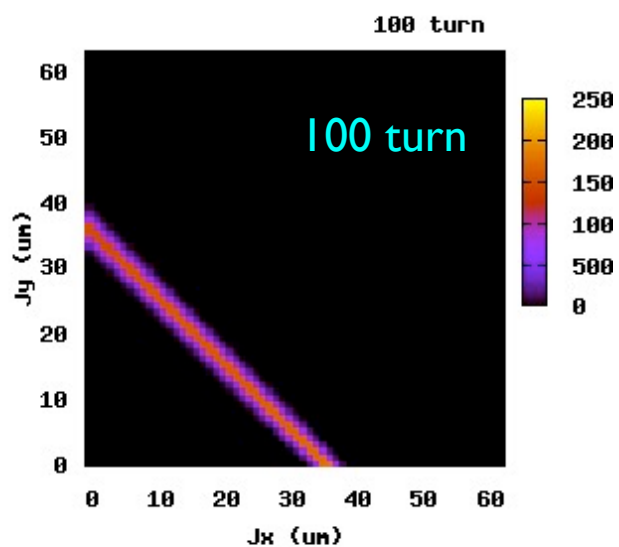
KV beam injected in MR, $25\pi \mu\text{m}$

Data is accumulated in 100 turns

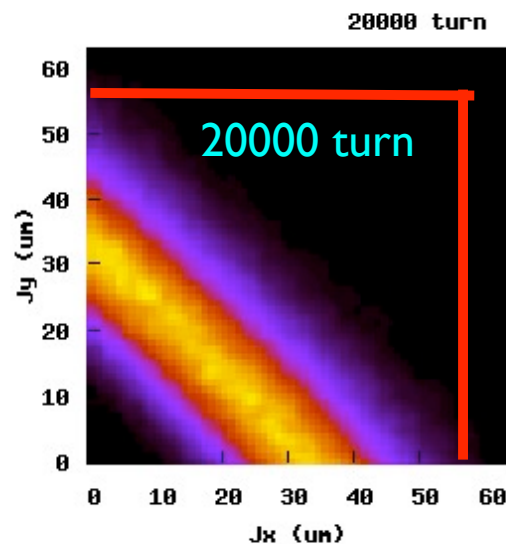
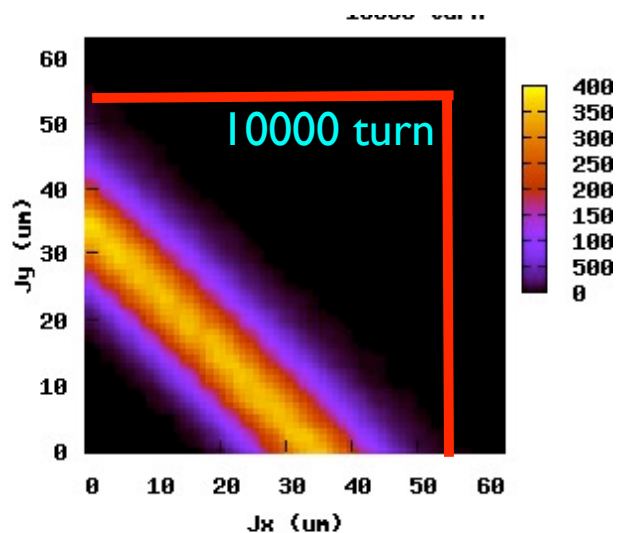


Spreading of $J_x + J_y$

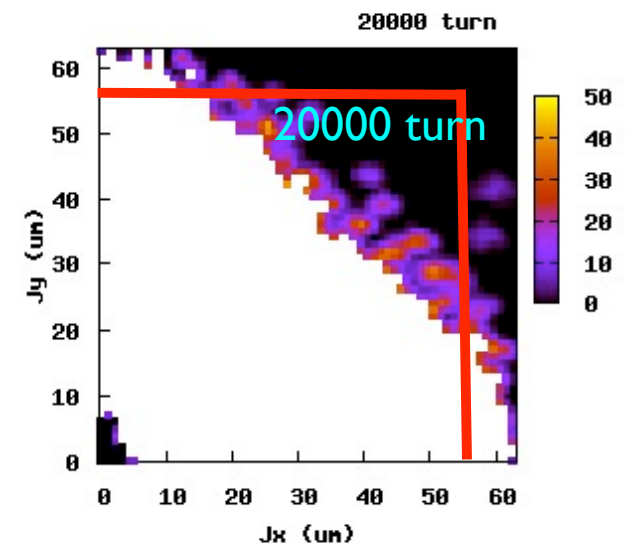
KV beam injected in MR, $37.5\pi \mu\text{m}$



0.23% loss
172 W



Acceleration starts after 23000 turns



Summary

- MR 750kW operation is very hard even in the ideal lattice.
- It remains a little possibility for 0.45Hz repetition. We have to study RCS injection in detail.
- Higher probability for 0.75Hz, $0.6 \times N_p = 2.5 \times 10^{13}$ /bunch.
- Realistic painting will be tried in the simulation.
- Decide maximum intensity in the ideal lattice. Estimate error tolerance. Then choose the repetition, ~ 1 Hz?.
- How much tolerance for errors in $0.6 N_p$, 0.75 Hz. repetition?

**Thanks for your
attention**